

## 1. Summary of Experimental Stations

### 1-1. Outline

There are 70 experimental stations on the PF storage ring and the PF-AR, as shown in Figs. 1 and 2. Two thirds of them are dedicated for research using hard X-rays, while the rest one third in the VUV and soft X-ray region. These experimental stations are summarized to designate research fields

carried out on them in Tables 1 and 2, respectively, for the PF storage ring and PF-AR. Each experimental station has a different specification in optics and performance depending on the methodology performed. Tables 3 and 4 list the optics of hard X-ray and soft X-ray or VUV stations, respectively, together with the principal performances, such as energy range, spot size, photon flux and energy resolution.

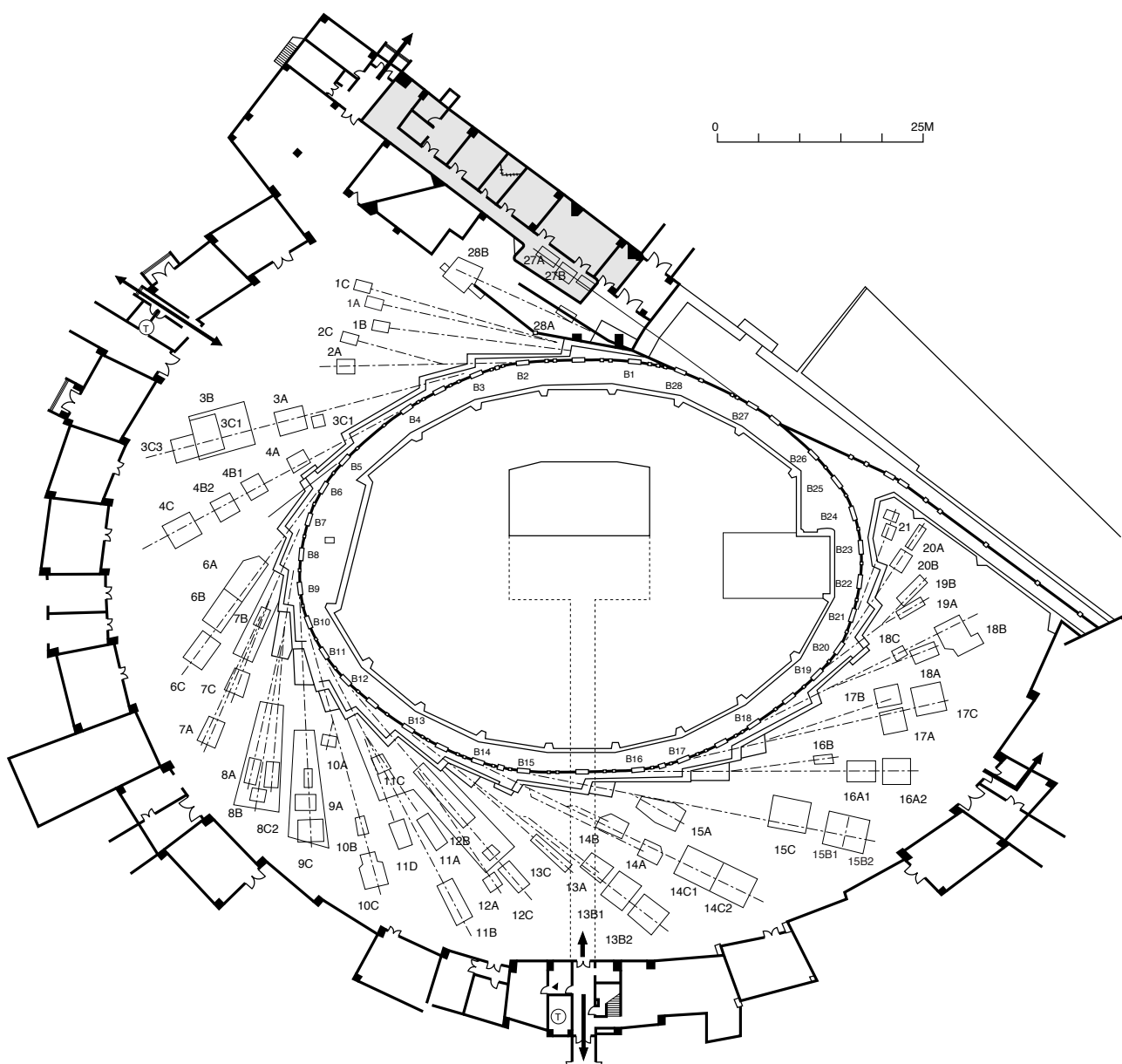


Figure 1.  
Plan view of the PF experimental hall.

Table 1. List of Experimental Stations at the PF Storage Ring.

Experimental Station	Spokesperson
BL-1	
A X-ray powder diffraction under extreme condition (under construction)	H.Nakao
B X-ray powder diffraction under extreme condition	H.Nakao
C VUV and soft X-ray photoelectron spectroscopy	T.Saitoh, M.Nakatake
BL-2 (Undulator)	
A Soft X-ray spectroscopy	Y.Kitajima
C Soft X-ray spectroscopy	A.Yagishita
BL-3	
A X-ray diffraction and scattering	M.Tanaka
B VUV and soft X-ray spectroscopy	Y.Azuma
C1 X-ray diffraction	H.Adachi, H.Kawata
C2 Characterization of X-ray optical elements	M.Ando
C3 X-ray magnetic Bragg scattering by means of white X-rays	H.Adachi, H.Kawata
BL-4	
A Trace element analysis, X-ray microprobe	A.Iida
B1 Micro-crystal and -area structure analysis	K.Ohsumi
B2 Powder diffraction	M.Tanaka
C X-ray diffraction and scattering	H.Nakao
BL-6	
A Macromolecular crystallography	N.Igarashi
B [SBSF]Macromolecular crystallography by Weissenberg camera	N.Sakabe[SBSF], M.Suzuki
C [SBSF]Macromolecular crystallography by Weissenberg camera	N.Sakabe[SBSF], M.Suzuki
BL-7	
A [RCS]Soft X-ray XAFS, XMCD, XPS	K.Amemiya[RCS], K.Ito
B [RCS]Surface photochemical reaction and angle resolved photoelectron spectroscopy	K.Amemiya[RCS], K.Ito
C X-ray spectroscopy and diffraction	T.Iwazumi
BL-8	
A [Hitachi]Soft X-ray spectroscopy	K.Ogata[Hitachi], K.Mase
B [Hitachi]EXAFS	K.Ogata[Hitachi], K.Mase
C [Hitachi]X-ray tomography and X-ray microscopy	K.Ogata[Hitachi], K.Mase
BL-9	
A XAFS	M.Nomura
C X-ray versatile station	M.Nomura
BL-10	
A X-ray diffraction/scattering	M.Tanaka
B XAFS	N.Usami
C Small-angle X-ray scattering of solution sample	K.Kobayashi
BL-11	
A Soft X-ray spectroscopy	Y.Kitajima
B Surface EXAFS, soft X-ray spectroscopy	Y.Kitajima
C VUV spectroscopy (solid state)	M.Nakatake
D VUV and soft X-ray photoelectron spectroscopy for solid	T.Saitoh
BL-12	
A Characterization of VUV-SX optical elements, soft X-ray spectroscopy	A.Yagishita
B VUV high-resolution spectroscopy	K.Ito
C XAFS	M.Nomura

Experimental Station	Spokesperson
BL-13 (Multipole Wiggler/Undulator)	
A Laser-heating high-pressure and high-temperature X-ray diffraction (DAC)	T.Kikegawa
B1 Surface-sensitive XAFS, X-ray diffraction	T.Kikegawa
B2 High-pressure and high-temperature X-ray diffraction	T.Kikegawa
C Soft X-ray photoemission spectroscopy and XAFS	K.Mase
BL-14 (Vertical Wiggler)	
A Crystal structure analysis, EXAFS	S.Kishimoto
B High-precision X-ray optics	K.Hirano
C1 Medical applications and General purpose (X-ray)	K.Hyodo
C2 High-pressure and high-temperature X-ray diffraction (MAX-III)	T.Kikegawa
BL-15	
A Small-angle X-ray scattering of muscle and alloys	M.Suzuki
B1 White X-ray topography and X-ray magnetic Bragg scattering	H.Kawata
B2 Surface and interface diffraction	H.Sugiyama, H.Kawata
C High-resolution X-ray diffraction	K.Hirano
BL-16 (Multipole Wiggler/Undulator)	
A1 General purpose (X-ray)	H.Nakao
A2 X-ray diffraction and scattering	H.Nakao
B Soft X-ray spectroscopy	J.Adachi
BL-17	
A [Fujitsu]XAFS	N.Awaji[Fujitsu], A.Iida
B [Fujitsu]Photochemical vapor deposition	N.Awaji[Fujitsu], A.Iida
C [Fujitsu]Grazing incident X-ray diffraction, X-ray fluorescence analysis	N.Awaji[Fujitsu], A.Iida
BL-18	
A [ISSP]Angle-resolved photoelectron spectroscopy of surfaces and interfaces	T.Kinoshita[ISSP], T.Saitoh
B Macromolecular crystallography	M.Suzuki
C High pressure X-ray powder diffraction (DAC)	T.Kikegawa
BL-19 (Revolver Undulator)	
A [ISSP]Spin-resolved photoelectron spectroscopy (Mott detector)	T.Kinoshita[ISSP], T.Saitoh
B [ISSP]Spin-resolved photoelectron spectroscopy (SPLEED)	S.Shin[ISSP], T.Saitoh
[ISSP]Soft X-ray emission spectroscopy	
BL-20	
A VUV spectroscopy	K.Ito
B [ANBF]White and monochromatic beam general purpose X-ray station	G.Foran[ANBF], K.Ohsumi
BL-21 [Light Source Division]Beam position monitoring	M.Kobayashi[Light Source]
BL-27 (Beamline for experiments using radioisotopes)	
A Radiation biology, soft X-ray photoelectron spectroscopy	K.Kobayashi
B Radiation biology, XAFS, X-ray diffuse scattering	N.Usami
BL-28 (Elliptical Multipole Wiggler / Helical Undulator)	
A VUV and soft X-ray spectroscopy with circularly polarized undulator radiation	T.Koide
B Spectroscopy and scattering with circularly polarized X-rays	T.Iwazumi
SBSP Structural Biology Sakabe Project, Foundation for Advancement of International Science	
RCS Research Center for Spectrochemistry, the University of Tokyo	
ISSP Institute for Solid State Physics, the University of Tokyo	
ANBF Australian National Beamline Facility	

Table 2. List of Experimental Stations at the PF-AR.

Experimental Station	Spokesperson
AR-NE1 (Elliptical Multipole Wiggler / Helical Undulator)	
A1 High-resolution Compton and magnetic Compton scattering	H.Kawata
A2 Coronary Angiography	K.Hyodo
B Spectroscopy with circularly polarized soft X-rays	T.Koide
AR-NE3 (Undulator)	
A Nuclear resonant scattering	X.Zhang
AR-NE5	
A Medical applications	K.Hyodo
B Bunch-purity and beam-position monitoring	S.Kishimoto
C High pressure and high temperature X-ray diffraction (MAX-80)	T.Kikegawa
AR-NE9	
B [Accelerator Laboratory] Vacuum science and technology	K.Kanazawa[Acc.Lab.]
AR-NW2 (Undulator)	
A XAFS/Dispersive XAFS (under construction)	M.Nomura
AR-NW12 (Undulator)	
A Macromolecular crystallography (under construction)	N.Matsugaki

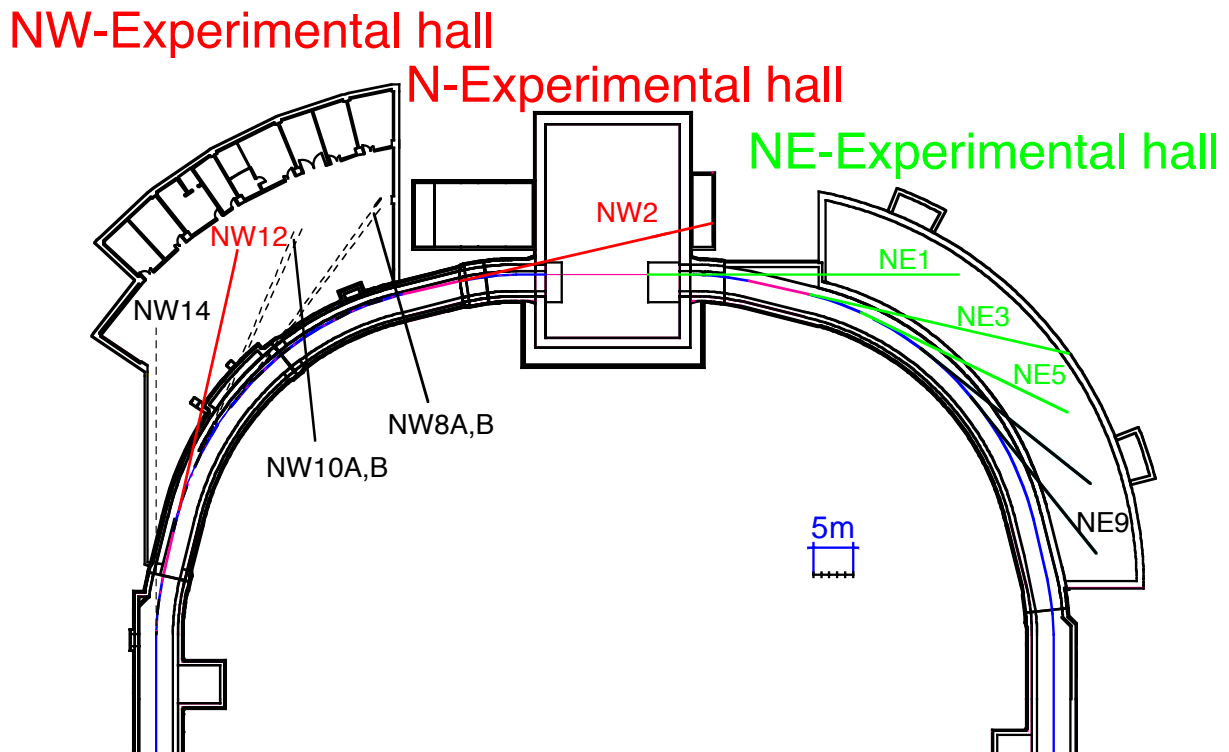


Figure 2.

Plan view of the beamlines in the PF-AR north-east, north, and north-west experimental halls.

Table 3. X-Ray Beamline Optics.

Branch Beamline	Horizontal Acceptance (mrad)	Type of Monochromator	Mirror	Photon Energy (keV)	Beam Size (HxV) (mm)	Photon Flux at Sample Position (/s)	Energy Resolution ( $\Delta E/E$ ) $\times 10^{-4}$	Reference
BL-1B	2	Flat Double Crystal Si(111)	Bent Cylinder	6 ~ 21	0.7x0.5	$8 \times 10^{10}/4\text{mm}^2$ (8.3 keV, 300 mA)	~ 5	1
BL-3A	4	Double Crystal Si(111) Sagittal Focusing	Collimating Focusing Mirrors (Fused Quartz)	6 ~ 20	100x5 2x1		~ 2	2 - 4
BL-3C2	2	Double Crystal Si(111), Si(311)	None	4 ~ 20 6 ~ 34	5x2	$1 \times 10^{10}$ $2 \times 10^9$		
BL-3C3	2	Double Crystal Si(111)	None	5 ~ 30 or white	20x4 0.1x0.1			
BL-4A	6	Double Crystal Sagittal Focusing	None	4 ~ 20	50x4 4x1		~ 2	5
BL-4B1	4.5	Double Crystal Si(111)	None	4 ~ 35	50x5		~ 2	6
BL-4B2	4.5	Double Crystal Si(111)	Bent Cylinder	6 ~ 20	13x2		~2	7, 8
BL-4C	2	Flat Double Crystal Si (111)	Bent Cylinder	6 ~ 21	0.7x0.5		~5	9, 10
BL-6A	1.2	Bent Si(111) ( $\alpha = 0^\circ, 6.0^\circ, 7.8^\circ, 9.5^\circ, 11.4^\circ, 13.7^\circ, 16.5^\circ$ )	Bent Plane Fused Quartz	5 ~ 25	2.5x1			11
BL-6B	1	Bent Si(111)	Bent Plane Si Pt-coated		1.7x0.2			12
BL-6C	2	Bent Si (111)	Bent Plane Si Pt-coated					13
BL-7C	4	Double Crystal Si (111) Sagittal Focusing	Double Mirror Fused Quartz Focusing	4 ~ 20 (4 ~ 13)	5x1	$1 \times 10^{10}/6\text{mm}^2$ (8 keV, 300 mA) ( $1 \times 10^{11}$ when focused)	~ 2	14 - 16
BL-8C	5	Channel-Cut Si(220), Si(111), Si(400)	None	5 ~ 40	50x5	$6 \times 10^9/\text{mm}^2$ (10 keV, 300 mA)	~2	
BL-9A	3	Double Crystal Si (111)	Collimating and Focusing Bent Conical Mirrors (Rh Coated) Double Flat Mirror (Rh/Ni Coated)	2.2 ~ 15	1x0.3	$4 \times 10^{11}$ (9 keV, 300 mA)	2	17, 18
BL-9C	3.5	Double Crystal Si(111)	Bent Cylinder Rh-coated Si	4 ~ 23 or white	1x1	$5 \times 10^{10}$ (9 keV, 300 mA)	~ 2	

## Experimental Facilities

Branch Beamline	Horizontal Acceptance (mrad)	Type of Monochromator	Mirror	Photon Energy (keV)	Beam Size (H×V) (mm)	Photon Flux at Sample Position (/s)	Energy Resolution ( $\Delta E/E$ )×10 <sup>-4</sup>	Reference
BL-10A	1	Si(111), Si(311) Quartz(100), PG(002) Curved Si(111) ( $\alpha \sim 4^\circ, 8^\circ$ )	Plane Pt coated Fused Quartz	5 ~ 25	10×3		10 ~ 5	19
BL-10B	2	Channel-Cut Si(311)	None	6 ~ 30	5×1	1×10 <sup>9</sup> /7mm <sup>2</sup>	1	
BL-10C	4	Double Crystal Si(111)	Bent Cylinder	4 ~ 10	1.2×0.2	~10 <sup>11</sup> /1.5mm <sup>2</sup> (8 keV, 400 mA)	2	
BL-12C	2	Double Crystal Si(111) Si(311)	Bent Cylinder	6 ~ 23	0.65×0.4	5×10 <sup>10</sup> /1mm <sup>2</sup> (8 keV, 300mA) w.Si(111)	~ 2	20
BL-13A	1	Double Crystal Si(111), Ge(111)	Cylinder Pt-coat Fused Quartz	30	0.045×0.032	5×10 <sup>10</sup> /1mm <sup>2</sup>	~ 2	21
BL-13B1 B2	4	Double Crystal Si(111), Si(220) Sagittal Focusing	Bent Plane Fused Quartz	4 ~ 30	4×1		~ 2	22
BL-14A	1.28 (Vertical)	Double Crystal Si (111) Si (311) Si (553)	Bent Cylinder Pt-coated Fused Quartz	5.1 ~ 19.1 9.9 ~ 35.6 22.7 ~ 84.5	2×1 at focus 5×38		2	23
BL-14B	2.2 (Vertical)	Double Crystal Si(111),	None	10 ~ 57	5×14		2	
BL-14C1 C2	1.3 (Vertical)	Double Crystal Si(111), Si(220)	None	5 ~ 100 or white	6×35		2	24, 25
BL-15A	2	Bent Crystal Ge(111) ( $\alpha = 8.0^\circ$ )	Bent Plane, Fused Quartz Pt-coated	8.0 (fixed)	0.5×0.25	9×10 <sup>10</sup> /mm <sup>2</sup> (8.0 keV, 350 mA)	~ 10	26
BL-15B1 B2	2	Double Crystal Si (111)	Bent Cylinder	5 ~ 20 or white	0.6×0.4	10 <sup>11</sup> /1mm <sup>2</sup> (8.0keV, 350mA)	~ 2	
BL-15C	2	Double Crystal Si (111)	None	4 ~ 30	60×6			
BL-16A1 A2	1	Double Crystal Si(111) Sagittal Focusing	Bent Plane (Ph on Si) and Bent Plane (Rh on SiC)	4 ~ 25	1.2×0.5	~1×10 <sup>13</sup> (8.3 keV, 300 mA)	~ 1	27
BL-17A	4	Double Crystal Si(111)	None	5 ~ 13	100×10		~ 2	28
BL-17C	1	Double Crystal Si(111)	None	5 ~ 13	20×5		~ 2	29

Branch Beamline	Horizontal Acceptance (mrad)	Type of Monochromator	Mirror	Photon Energy (keV)	Beam Size (H×V) (mm)	Photon Flux at Sample Position (/s)	Energy Resolution ( $\Delta E/E$ ) $\times 10^{-4}$	Reference
BL-18B	2	Double Crystal Si(111) Si(220) Ge(111) Ge(220)	Bent Cylinder Fused Quartz, Pt-coated	6 ~ 30	0.6×0.4	$1.1 \times 10^{10}$ (12.4 keV, 300 mA) Si(111)	~ 2	30
BL-18C	1	Double Crystal Si(111)	Cylinder Fused Quartz, Pt-coated	6~25	0.07×0.04		~2	
BL-20B	2	Channel Cut Si(111) Double Crystal Sagittal focusing Si(111)	None	4 ~ 25	26×3		~ 2	31
BL-27B	4	Double Crystal Si(111)	None	4 ~ 20	100×6		~ 2	32
BL-28B	H: 4 V:0.2	Double Crystal Si(111) Si (220) InSb(111)	Pre-mirror Bent Cylinder Si Pt- & Ni-coated Post-mirror Bent Plane Fused Quartz Pt- & Ni-coated	2 ~ 10	2.0×0.2	$3 \times 10^{10}$ (9 keV, 300mA Si(220) Pc ~ 0.5)	~ 2 (Si(111))	33
AR-NE1A1	2	Double Bent Crystal Si(111) Si(400)		40 ~ 70 80 ~ 160	2×0.5	$2 \times 10^{13}$ (60 keV, 35mA)	8	34-36
AR-NE1A2	2	Asym. cut Single Crystal Si(311)		33 ~ 38	75×120 ~140	$10^{10}$ (33 keV)	60	
AR-NE3	H:0.3 V:0.03	Double Crystal Si(111) High-resolution Monochromator Nuclear Monochro- mator of Single Cryst- tal $^{57}\text{Fe}_2\text{O}_3$ (777)		5 ~ 25 8 ~ 26 14.4	15×2	$1 \times 10^9$ (14.4 keV)	1 $5 \times 10^{-3}$ $1 \times 10^{-7}$	37
AR-NE5A	10	Asym.Cut Single Crystal Si(311), Si(511) ( $\alpha = 4^\circ \sim 6^\circ$ ) Double Crystal Si (311), Si(111), Si(220)		20 ~ 60 20 ~ 100	150×80 100×3	$5 \times 10^8$ (33.2 keV)	60 2	38, 39
AR-NE5C	3	Double Crystal Si (111)	None	30 ~ 100 or white	60×5		5	40

References

- [1] A. Fujiwara et al., *J. Appl. Cryst.* 33 (2000) 1241.
- [2] S. Sasaki et al., *Rev. Sci. Instrum.* 63 (1992) 1047.
- [3] K. Kawasaki et al., *Rev. Sci. Instrum.* 63 (1992) 1023.
- [4] T. Mori and S. Sasaki, *Rev. Sci. Instrum.* 66 (1995) 2171.
- [5] A. Iida et al., *Rev. Sci. Instrum.* 66 (1995) 1373.
- [6] K. Ohsumi et al., *Rev. Sci. Instrum.* 66 (1995) 1448.
- [7] Powder Diffraction User Group, KEK Report 94-11 (1995).
- [8] H. Toraya, H. Hibino and K. Ohsumi, *J. Synchrotron Rad.* 3 (1996) 75.
- [9] H. Iwasaki et al., *Rev. Sci. Instrum.* 60 (1989) 2406.
- [10] Photon Factory Activity Report 1995 #13 (1996) E-1.
- [11] N. Sakabe et al., *Rev. Sci. Instrum.* 66 (1995) 1276.
- [12] Photon Factory Activity Report 1995 #13 (1996) C-1.
- [13] N. Sakabe et al., *Nucl. Instrum. Meth. A* 467-468 (2001) 1367.
- [14] M. Nomura and A. Koyama, KEK Internal 93-1 (1993).
- [15] M. Nomura et al., KEK Report 91-1 (1991).
- [16] M. Nomura and A. Koyama, in "X-ray Absorption Fine Structure," ed. by S. S. Hasnain, Ellis Horwood, Chichester, 1991, p.667.
- [17] M. Nomura and A. Koyama, *J. Synchrotron Rad.* 6 (1999) 182.
- [18] M. Nomura and A. Koyama, *Nucl. Instrum. Meth. A* 467-468 (2001) 733.
- [19] S. Sasaki, *Rev. Sci. Instrum.* 60 (1989) 2417.
- [20] M. Nomura and A. Koyama, KEK Report 95-15 (1996).
- [21] Photon Factory Activity Report 2000 #18 (2001) A.
- [22] Photon Factory Activity Report 1994 #12 (1995) C-6.
- [23] Y. Satow and Y. Iitaka, *Rev. Sci. Instrum.* 60 (1989) 2390.
- [24] Photon Factory Activity Report 1999 #17 (2000) A 92.
- [25] Photon Factory Activity Report 1999 #17 (2000) A 103
- [26] Y. Amemiya et al., *Nucl. Instrum. Meth.* 208 (1983) 471.
- [27] Photon Factory Activity Report 1994 #12 (1995) E-3.
- [28] Photon Factory Activity Report 1988 #6 (1988) I-15.
- [29] Y. Horii et al., *Rev. Sci. Instrum.* 66 (1995) 1370.
- [30] N. Watanabe et al., *Rev. Sci. Instrum.* 66 (1995) 1824.
- [31] R.F. Garret et al., *Rev. Sci. Instrum.* 66 (1995) 1351.
- [32] H. Konishi et al., *Nucl. Instrum. Meth. A* 372 (1996) 322.
- [33] T. Iwazumi et al., *Rev. Sci. Instrum.* 66 (1995) 1691.
- [34] H. Kawata et al., *Rev. Sci. Instrum.* 60 (1989) 1885.
- [35] H. Kawata et al., *J. Synchrotron Rad.* 5 (1998) 673.
- [36] H. Kawata et al., *Nucl. Instrum. Meth. A* 467-468 (2001) 404.
- [37] X. Zhang et al., *Rev. Sci. Instrum.* 63 (1992) 404.
- [38] K. Hyodo et al., *Handbook on SR IV*, (1991) 55.
- [39] Y. Itai et al., *Rev. Sci. Instrum.* 66 (1995) 1385.
- [40] T. Kikegawa et al., *Rev. Sci. Instrum.* 66 (1995) 1335.



Table 4. VUV and Soft X-ray Beamline Optics.

Branch Beamline	Acceptance Hor. & Ver. (mrad)	Type of Monochromator	Grating Groove Density (l/mm)	Photon Energy (eV)	Beam Size (mm)	Typical Resolving Power (E/ΔE) and Photon Flux (/s)	Reference
BL-1C	5 3	Varied-Space Plane Grating	300 600 1200	20 ~ 60 40 ~ 120 80 ~ 240	1 × 1	1000 ~ 10000 10 <sup>11</sup> ~ 10 <sup>9</sup>	1
BL-2A Undulator	K = 0.5 ~ 2.2 λ <sub>U</sub> = 6 cm	Double Crystal InSb (111), Si (111)	—	1740 ~ 5000	< 1φ	2000, 8000 10 <sup>11</sup>	2 - 5
BL-2C Undulator	K = 0.55 ~ 2.2 λ <sub>U</sub> = 6 cm	Varied-Space Plane Grating	1000 2200	250 ~ 1400	0.9 × 0.1	5000 ~ 10000 10 <sup>11</sup> ~ 10 <sup>10</sup>	6-8
BL-3B	10 2	Grazing Incidence R = 24 m α+β = 165°	200 600 1800	10 ~ 280	< 2φ	200 ~ 3000 10 <sup>12</sup> ~ 10 <sup>9</sup>	9, 10
BL-7A (RCS)	6 1	Varied-Line-Space Plane Grating	150 300 650	50 ~ 1500	2.5 × 0.5	1000 ~ 9000 10 <sup>12</sup> ~ 10 <sup>9</sup>	
BL-7B (RCS)	6 4	1m Seya-Namioka	1200 2400	5 ~ 50	1 × 1	1000	11
BL-8A (Hitachi)	0.5 1	SX700 Plane Grating	1221	38 ~ 2300	5 × 1	2000 10 <sup>10</sup>	
BL-8B (Hitachi)	3 0.5	Double Crystal InSb (111), Si (311)	—	1700 ~ 14000	1.9 × 0.5	5000	12
BL-11A	5 1	Varied-Line-Space Plane Grating	300 800 1200	70 ~ 1900	2 × 1	500 ~ 5000 10 <sup>12</sup> ~ 10 <sup>9</sup>	13 - 16
BL-11B	4 0.6	Double Crystal InSb (111), Ge (111)	—	1760 ~ 3910	5 × 2	2000 10 <sup>10</sup>	4, 17, 18
BL-11C	4.8 3	1m Seya-Namioka	1200	4 ~ 35	~1φ	1000	19
BL-11D	4 2	Varied-deviation angle-type Grazing Incidence On-blaze Mount R <sub>1</sub> = 52.5 m R <sub>3</sub> = 22.5 m	2400	G <sub>3</sub> 60~245 G <sub>1</sub> 200~900	1 × 0.1	2000 10 <sup>11</sup>	20
BL-12A	2.2 0.34	Grazing Incidence R = 2 m α = 88°	1200	30 ~ 1000	2 × 3	1000 10 <sup>9</sup>	21
BL-12B	5 3.6	6.65 m Off-Plane Eagle	1200 4800	5 ~ 30	—	2.5 × 10 <sup>5</sup> 10 <sup>4</sup>	22 - 24
BL-13C Undulator	K = 0.3 ~ 4.2 λ <sub>U</sub> = 18 cm	Grazing Incidence R = 50 m α+β = 173.2°	350 750	70 ~ 500 150 ~ 1000	5 × 1	1000 ~ 6000 10 <sup>12</sup> ~ 10 <sup>10</sup>	25, 26

Branch Beamline	Acceptance Hor. & Ver. (mrad)	Type of Monochromator	Grating Groove Density (l/mm)	Photon Energy (eV)	Beam Size (mm)	Typical Resolving Power (E/ΔE) and Photon Flux (/s)	Reference
BL-16B Undulator	K = 0.5 ~ 5.75 $\lambda_U = 12$ cm	Grazing Incidence R = 24 m $\alpha + \beta = 168.6^\circ$	400 900 2000	40 ~ 550	< 1 $\phi$	1000 ~ 10000 $10^{12} \sim 10^{10}$	27 - 29
BL-17B (Fujitsu)	8 1	Toroidal Mirror	—	—	10 × 1	—	—
BL-18A (ISSP)	2 2	Grazing Incidence R = 3 m $\alpha + \beta = 160^\circ$ R = 6.65 m $\alpha + \beta = 167.5^\circ$	300 600 1200 500	15 ~ 150	< 1 $\phi$	1000~2000 $10^{11} \sim 10^9$	30
BL-19A Revolver Undulator (ISSP)	K = 1.0 ~ 9.0 $\lambda_U = 16.4$ cm K = 0.5 ~ 1.25 $\lambda_U = 5$ cm K = 0.5 ~ 2.5	Grazing Incidence R = 2 m $\alpha + \beta = 160^\circ$ R = 4 m $\alpha + \beta = 170^\circ$	600 1200 600 1200	12 ~ 250	< 0.7 $\phi$	1000 $10^{12}$	31, 32
BL-19B Revolver Undulator (ISSP)	$\lambda_U = 7.2$ cm K = 1.0 ~ 5.0 $\lambda_U = 10$ cm	Varied-space Plane Grating	800 2400	10 ~ 1200	< 0.5 $\phi$	400~4000 $10^{12} \sim 10^{11}$	32-34
BL-20A	28 5	3m Normal Incidence	1200 2400	5 ~ 40	2 × 1	300 ~ 30000 $10^{12} \sim 10^8$	35
BL-27A	5 0.5	Double Crystal InSb (111)	—	1800 ~ 4000		2000	36
BL-28A Helical Undulator	$K_x = 0.23 \sim 3$ $K_y = 0.23 \sim 6$ $\lambda_U = 16$ cm	Grazing Incidence R = 2 m $\alpha + \beta = 160^\circ$ R = 4 m $\alpha + \beta = 170^\circ$	600 1200 600 1200	30 ~ 250	< 0.5 $\phi$	1000 $10^0$	37
AR-NE1B Helical Undulator	$K_x = 0.2 \sim 3$ $K_y = 0.2 \sim 6$ $\lambda_U = 16$ cm	Grazing Incidence R = 10m $\beta = 89^\circ$	1200 2400	250 ~ 1800	$\sim 0.8 \times 0.2$	1000~5000 $10^{11} \sim 10^9$	38, 39

## References

- [1] K. Ono et al., Nucl. Instrum. Meth. A467-468 (2001) 573.
- [2] H. Maezawa et al., Nucl. Instrum. Meth. A246 (1986) 310.
- [3] Y. Kitajima et al., Rev. Sci. Instrum. 63 (1992) 886.
- [4] Y. Kitajima, J. Elec. Spec. Relat. Phenom. 80 (1996) 405.
- [5] Y. Kitajima, J. Synchrotron Rad. 6 (1999) 167.
- [6] Y. Yan and A. Yagishita, KEK Report 95-9 (1995).
- [7] M. Watanabe et al., Proc. SPIE Vol. 3150 (1997) 58.
- [8] M. Watanabe et al., Nucl. Instrum. Meth. A467-468 (2001) 512.
- [9] A. Yagishita et al., Nucl. Instrum. Meth. A306 (1991) 578.
- [10] S. Masui et al., Rev. Sci. Instrum. 63 (1992) 1330.
- [11] H. Namba et al., Rev. Sci. Instrum. 60 (1989) 1917.
- [12] K. Ogata et al., Photon Factory Activity Report 1994 #12 (1995) 164.
- [13] K. Amemiya et al., J. Synchrotron Rad. 3 (1996) 282.
- [14] K. Amemiya et al., Proc. SPIE Proceedings 3150 (1997) 171.
- [15] Y. Kitajima et al., J. Synchrotron Rad. 5 (1998) 729.
- [16] Y. Kitajima et al., J. Elec. Spectrosc. Relat. Phenom. 101-103 (1999) 927.
- [17] T. Ohta et al., Nucl. Instrum. Meth. A246 (1986) 373.
- [18] M. Funabashi et al., Rev. Sci. Instrum. 60 (1989) 1983.
- [19] Photon Factory Activity Report 1982/1983 (1984) V-15.
- [20] Photon Factory Activity Report 1997 #15 (1998) A 101.
- [21] Photon Factory Activity Report 1992 #10 (1993) I-2.
- [22] K. Ito et al., Appl. Opt. 25 (1986) 837.
- [23] K. Ito et al., Appl. Opt. 28 (1989) 1813.
- [24] K. Ito and T. Namioka, Rev. Sci. Instrum. 60 (1989) 1573.
- [25] N. Matsubayashi et al., Rev. Sci. Instrum. 63 (1992) 1363.
- [26] H. Shimada et al., Rev. Sci. Instrum. 66 (1995) 1780.
- [27] E. Shigemasa et al., KEK Report 95-2 (1995).
- [28] Photon Factory Activity Report 1995 #13 (1996) E-2.
- [29] E. Shigemasa et al., J. Synchrotron Rad. 5 (1998) 777.
- [30] S. Suzuki et al., Activity Report of SRL-ISSP 60 (1989) .
- [31] A. Kakizaki et al., Rev. Sci. Instrum. 60 (1989) 1893.
- [32] A. Kakizaki et al., Rev. Sci. Instrum. 63 (1992) 367.
- [33] M. Fujisawa et al., Nucl. Instrum. Meth. A467-468 (2001) 309.
- [34] M. Fujisawa et al., Nucl. Instrum. Meth. A467-468 (2001) 313.
- [35] K. Ito et al., Rev. Sci. Instrum. 66 (1995) 2119.
- [36] H. Konishi et al., Nucl. Instrum. Meth. A372 (1996) 322.
- [37] Y. Kagoshima et al., Rev. Sci. Instrum. 63 (1992) 1289.
- [38] Y. Kagoshima et al., Rev. Sci. Instrum. 66 (1995) 1696.
- [39] Y. Kagoshima et al., Rev. Sci. Instrum. 66 (1995) 1534.